



Planar-Integrated Free-Space Optics as Interconnection Technology - Principle and Demonstration

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Round Table Meeting on: Optical Interconnects for High Throughput On Board Processors

9th February 2006

outline

- ONT-group at the University of Hagen and its focus of research
- concept of planar-integrated free-space optics (PIFSO)
- demonstrations on:
 - binary associative memory
 - massive parallel interconnects
 - integration technology
- issues

The ONT-Group

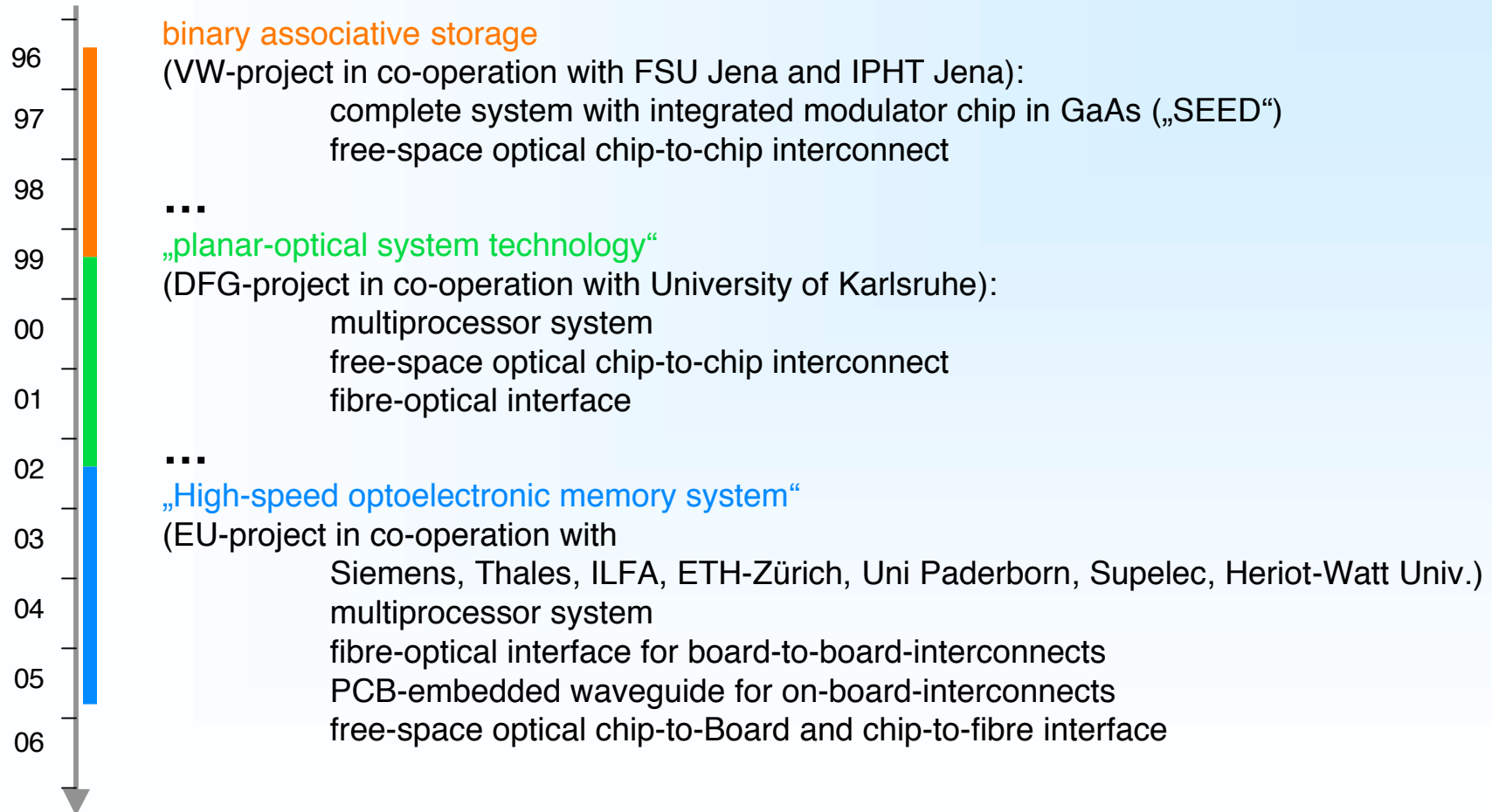
staff: around 10 scientific and technical co-workers or student assistants

research: microoptics, diffractive optics, microoptics integration, optical interconnects, signal processing

equipment: clean room with conventional optical lithography, RIE, thin film evaporation, etc. and optical labs

teaching: optical information technology, high-frequency engineering, MSc-extension course „Photonics“

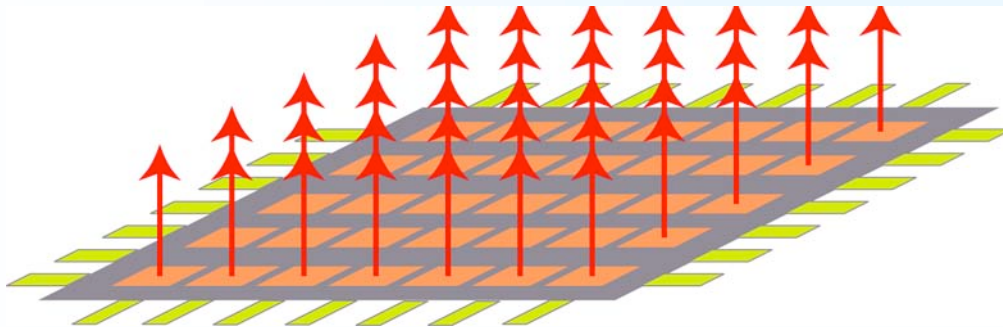
previous research at Hagen



Optical vs. electrical interconnection

Advantages of optics:

- large bandwidth (temporal, spatial)
 - RF immunity
- reduced power consumption at high data rates
 - **scaling properties**

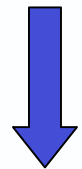
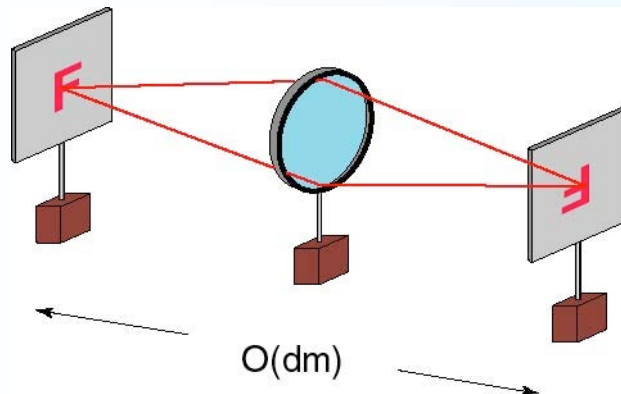


A - chip area

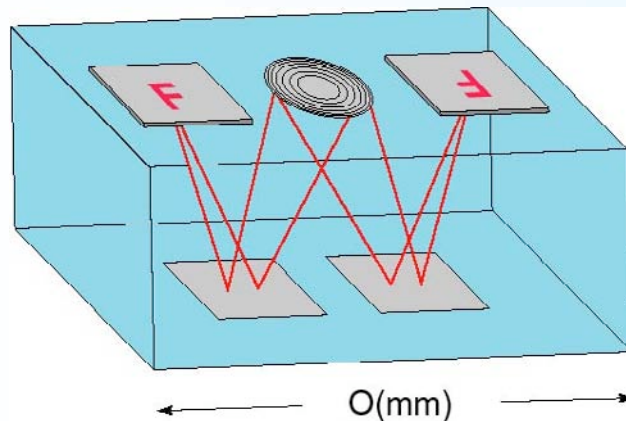
Scaling:

No. of devices: A
2-D connections: $A^{1/2}$
3-D connections: A

PIFSO principle



micro-integration into planar transparent wafer



J. Jahns, A. Huang, **Appl. Opt.** 28 (1989) 1602

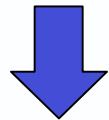
characteristic features:

- optical components at surfaces
- folded signal paths
- system-level design and fabrication
- compatibility with planar lithography-based methods
- 3-D topology with 2-D complexity
- suitable integration platform for opto-electronic components
- reliable monolithic micro-system for passive optical elements
- hybrid integration for active optical elements

PIFSO for optical interconnects ?

requirements:

- support parallelism
- VLSI compatibility
- compatibility to waveguiding optics
- interfacing technologies



fully satisfied by PIFSO

- supports dense channel packaging $> 1000 / \text{mm}^2$

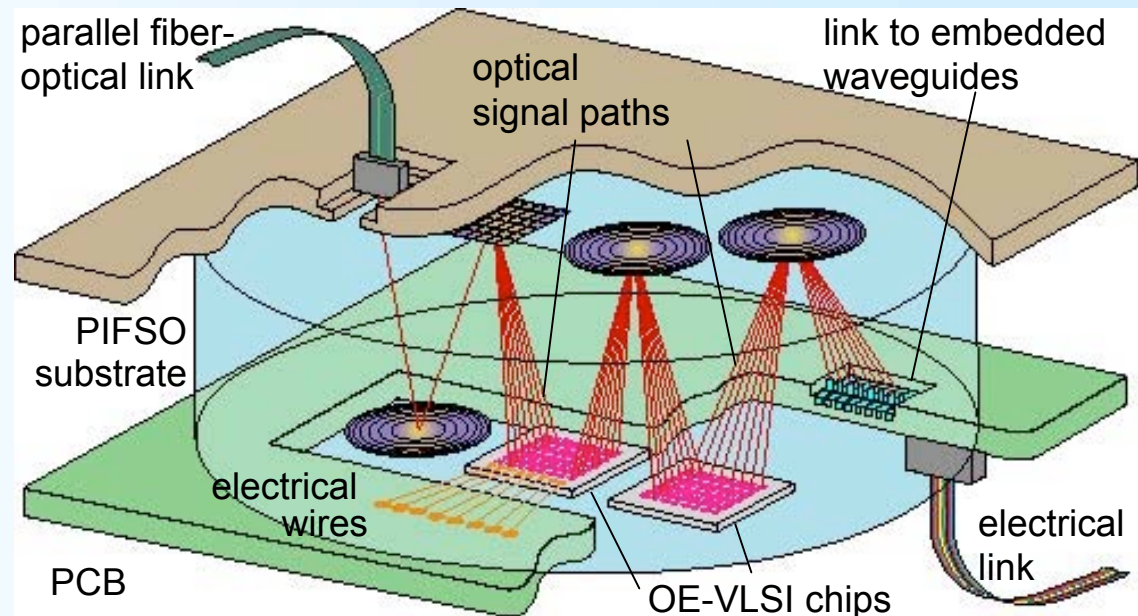
S. Sinzinger, J. Jahns, "Integrated micro-optical imaging system with a high interconnection capacity fabricated in planar optics ", Appl. Opt. **36**, p. 4729, 1997

- complex interconnection schemes (involving large fan-out and fan-in, 10x)

D. Fey, W. Erhard, M. Gruber, J. Jahns, H. Bartelt, G. Grimm, L. Hoppe, S. Sinzinger, "Optical interconnects for neural and reconfigurable VLSI Architectures", Proc. IEEE, 88, p. 838, 2000

- interfacing and packaging for OE-MCMs, fibre-optics and PCB waveguides

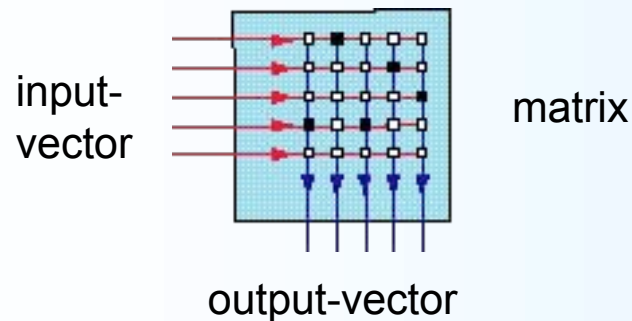
P. Lukowicz, et al., "Optoelectronic Interconnection Technology in the HOLMS System", IEEE JSTQE, 8, p. 624, 2000



project: binary associative storage

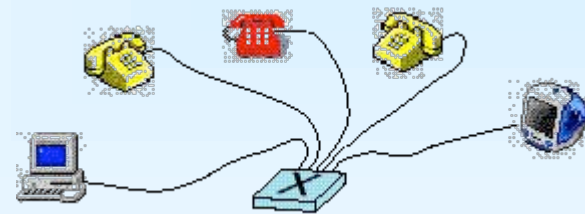
interconnect topology

vector-matrix-multiplication



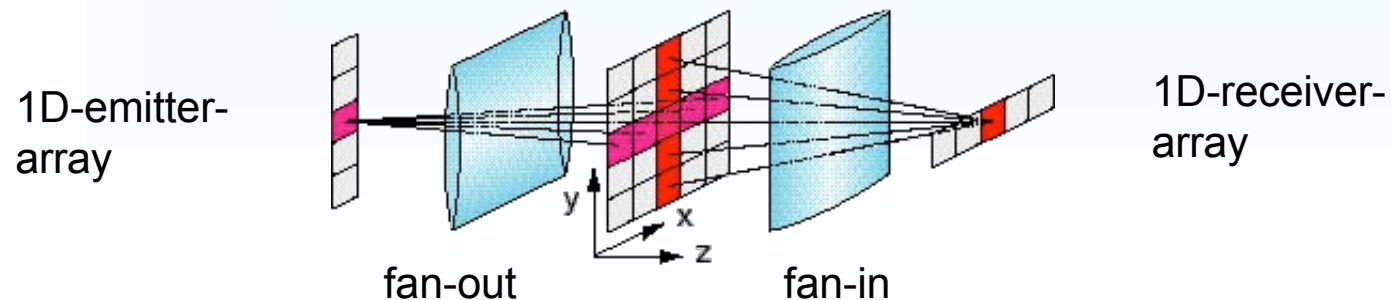
motivation

- general relevance for
- parallel optical computing
 - crossconnect switches

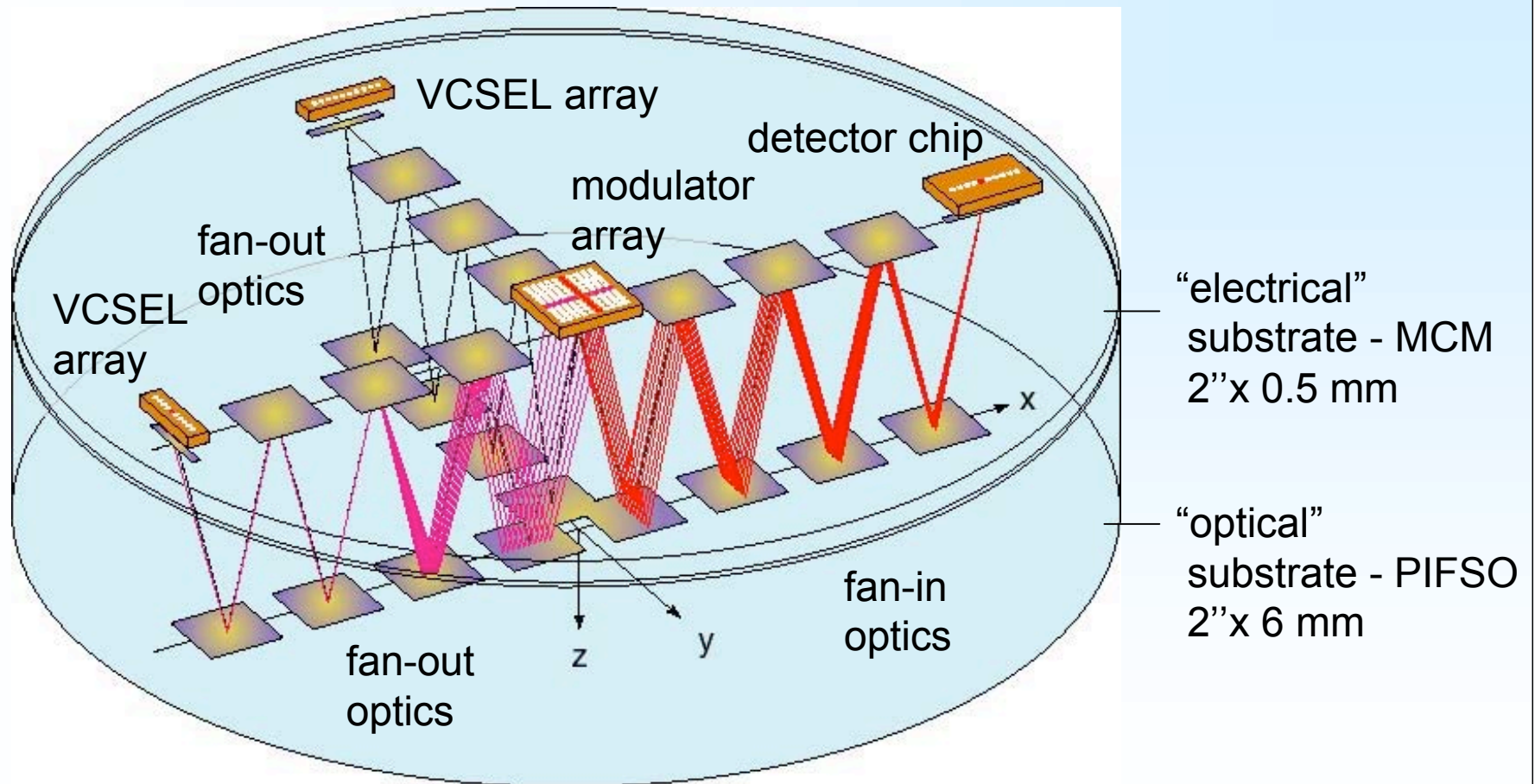


principal optical implementation

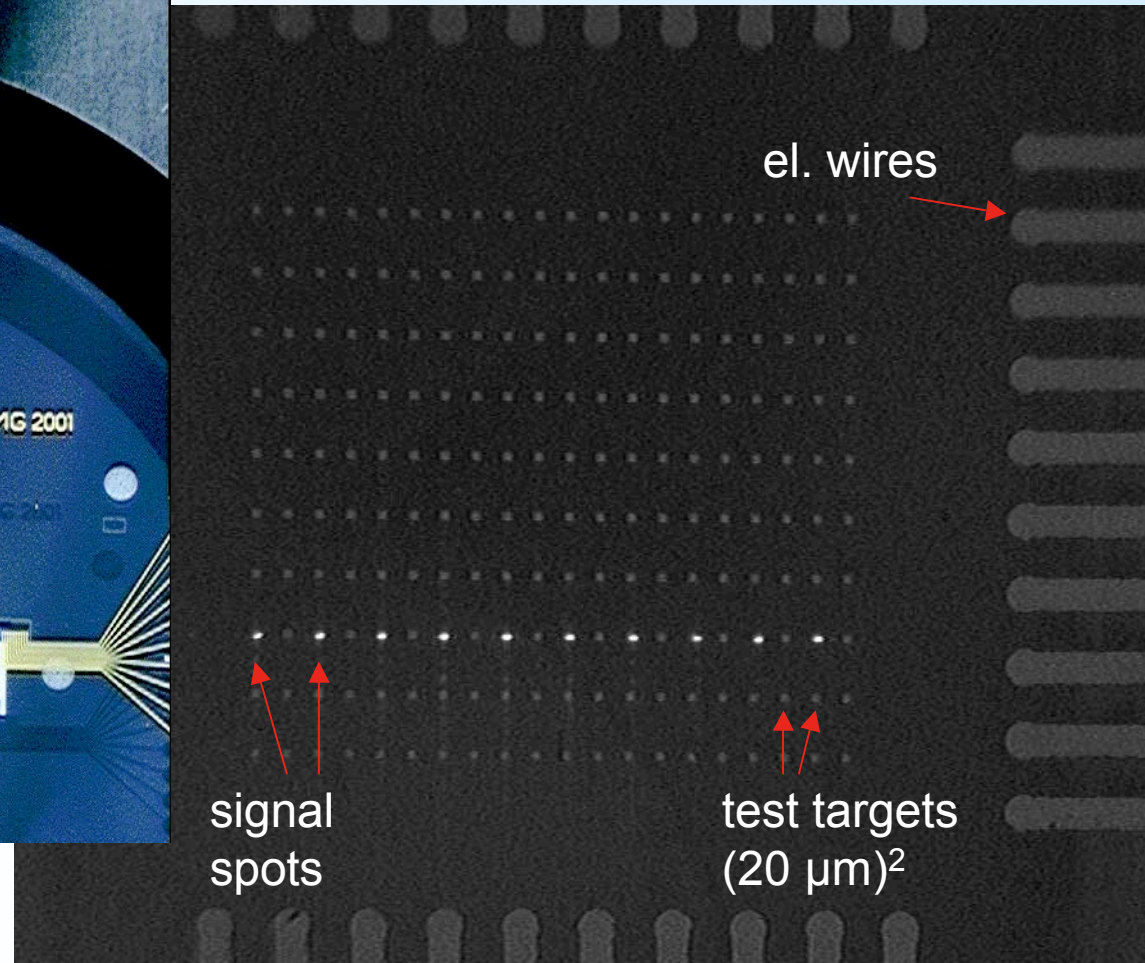
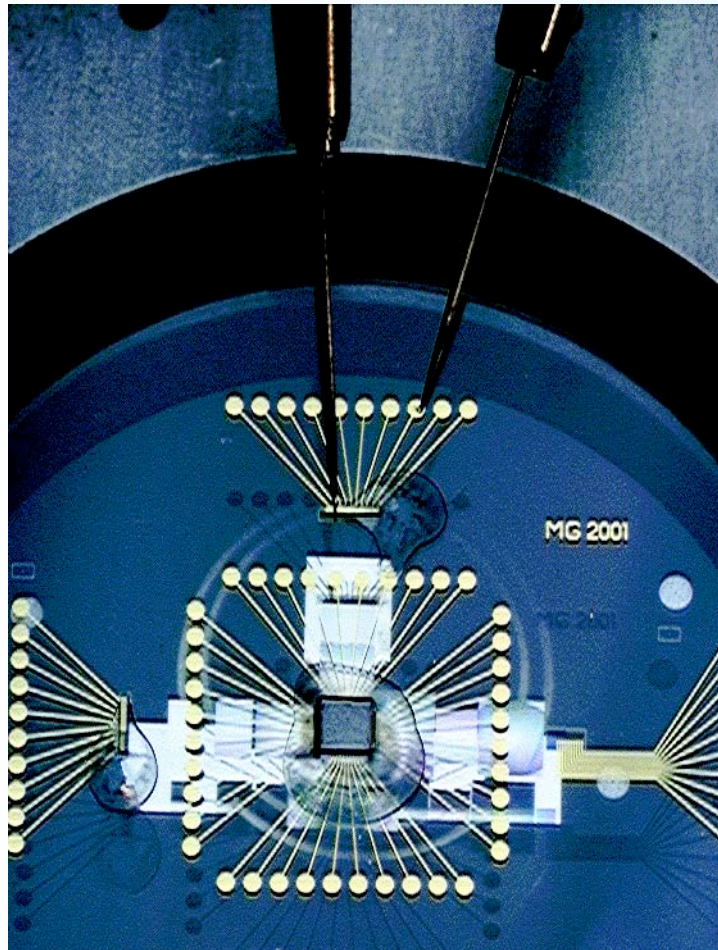
2D modulator array



PIFSO-type electro-optical multi chip module

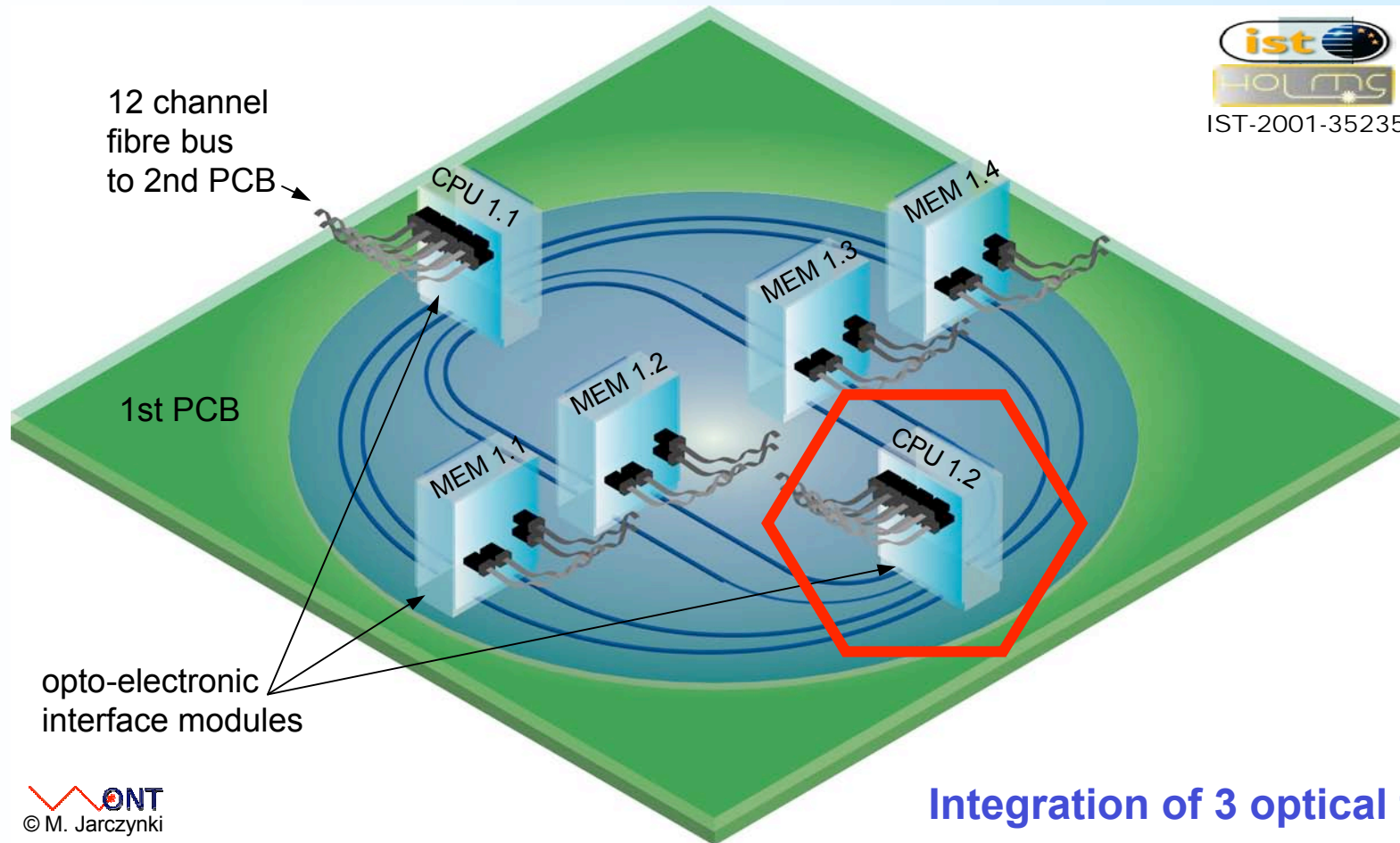


demonstrator and optical fan-out



project: high-speed opto-electronic memory systems

ist
HOLMS
IST-2001-35235

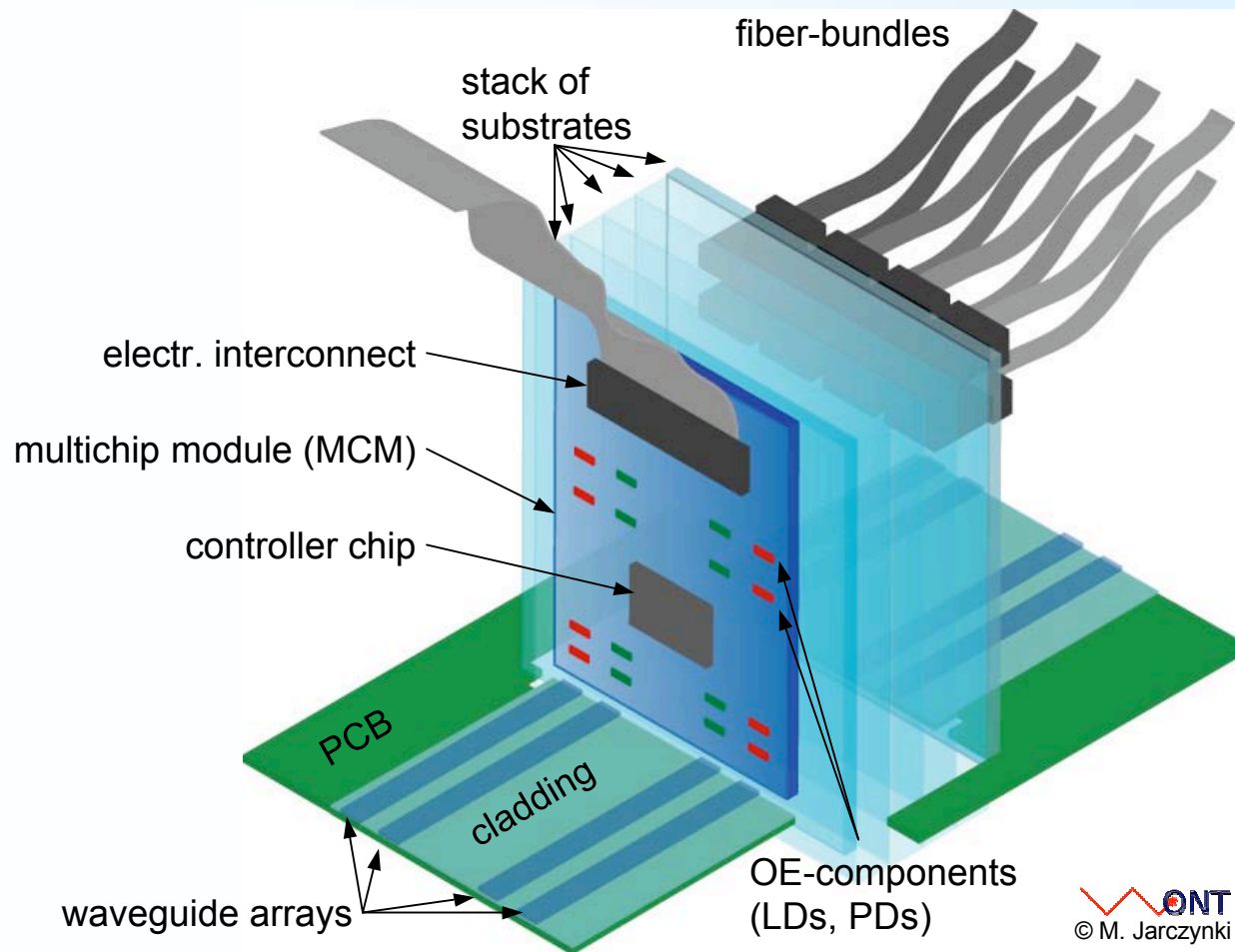


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Integration of 3 optical technologies

- ☞ fibre-optics
- ☞ embedded waveguide-optics
- ☞ free-space optics

details of packaging (3D free-space optical multilayer)



task and coupling of free-space optics:

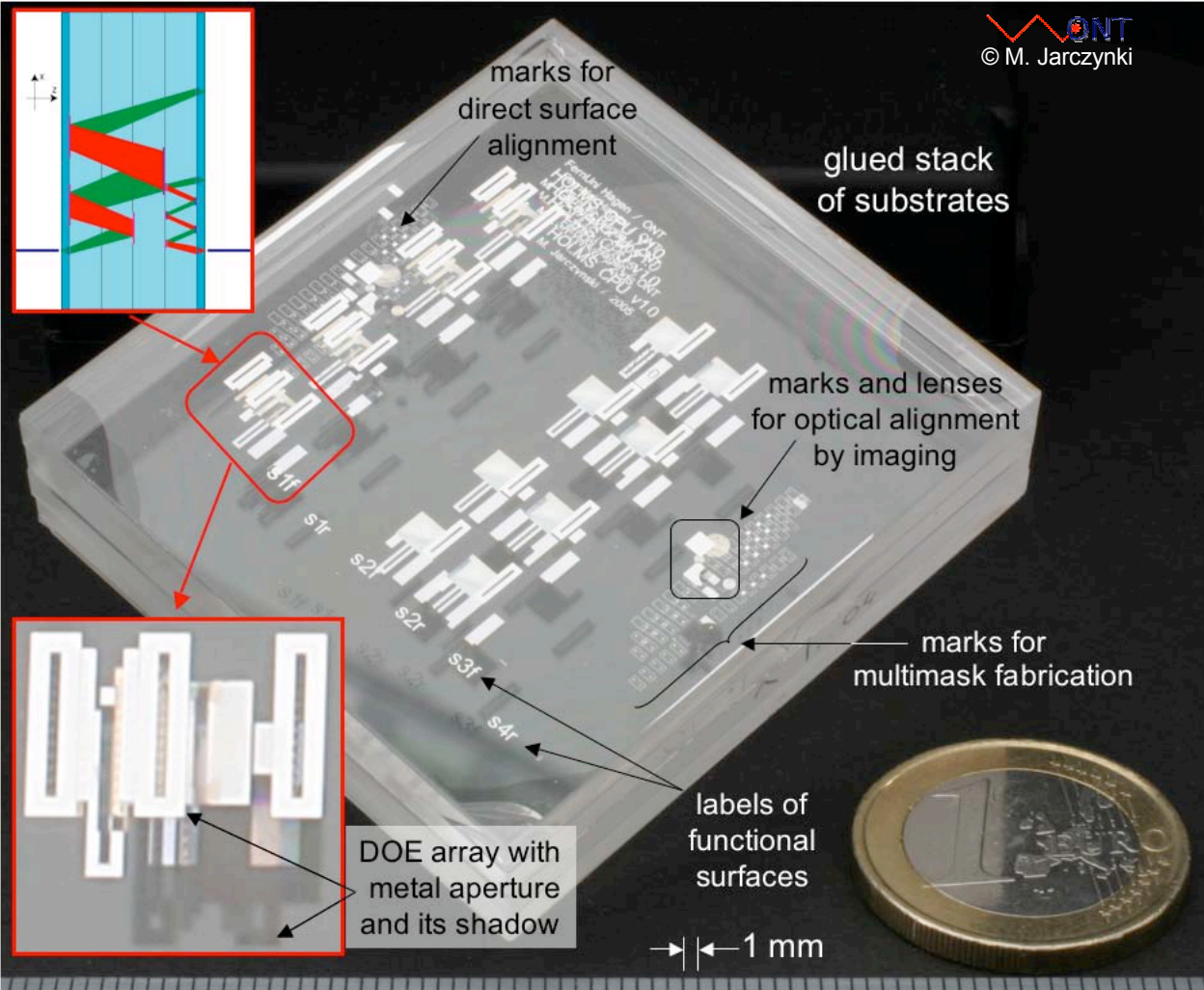
- ☞ signal distribution
- ☞ co-planar opto-electronic interfacing
- ☞ fibre-coupling
- ☞ waveguide coupling (vertical slot-concept)

special packaging of PIFSO:

- ☞ stack of several substrates
- ☞ internal functional surfaces
- ☞ increase of design freedom


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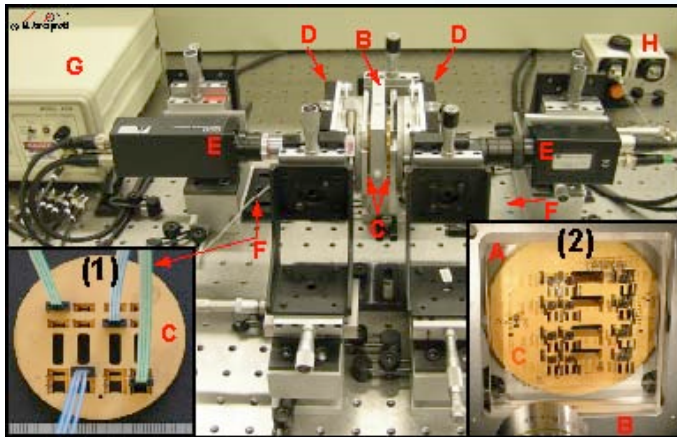
PIFSO-multilayer



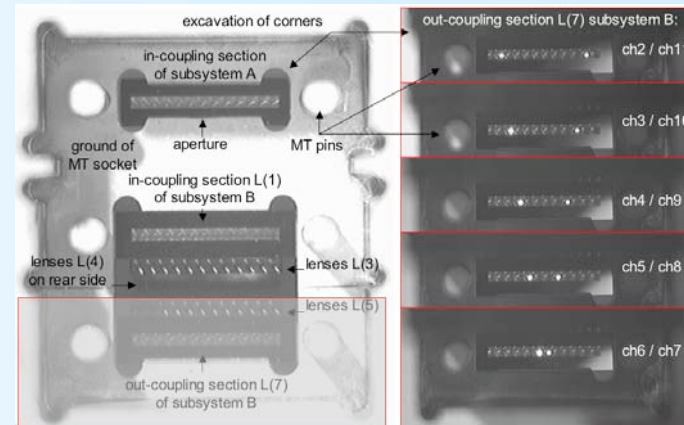
- ✓ 192 interconnects
- ✓ 6 functional surfaces
- ✓ 6 stacked substrates

experimental specification

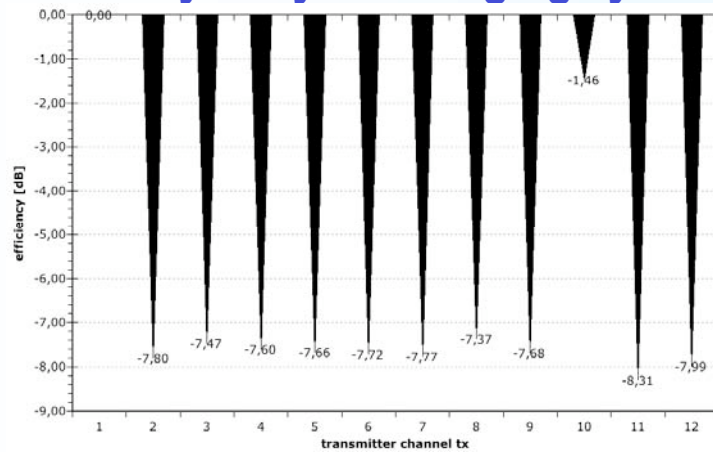
laboratory setup with metal interface plates (MIP)



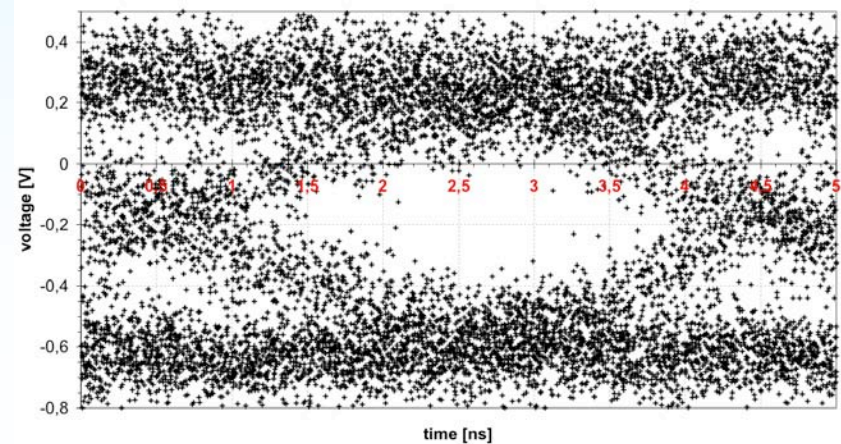
check of the interconnection



efficiency of hybrid imaging system

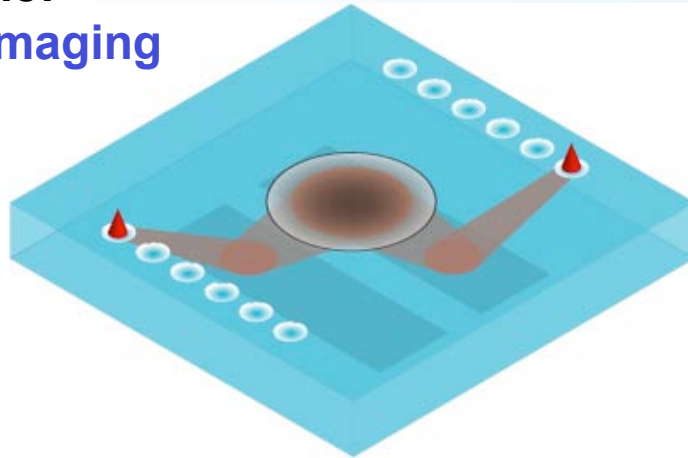


data transfer



implementation: diffractive optics

example:
array imaging

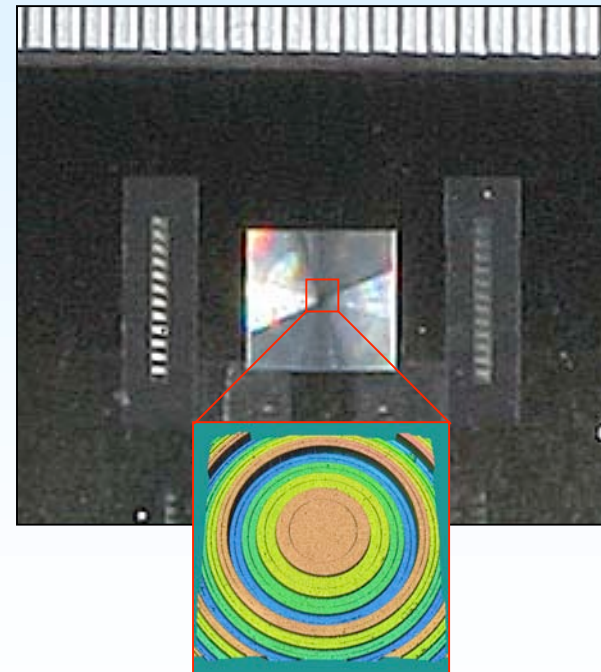


fabrication:

- e-beam mask
- lithography
- dry etching (RIE)

characteristics:

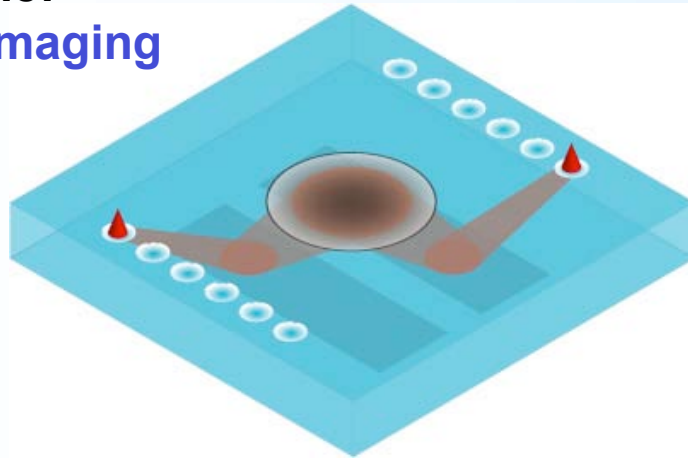
- $\eta_{\text{theor.}} = -3.9 \dots -5.6 \text{ dB}$
- $\eta_{\text{exp.}} = -3.6 \dots -6.6 \text{ dB}$
- crosstalk
- suppression: $> 31 \text{ dB}$
- single-mode operation



M. Jarczyński, J. Jahns, "Planar integrated free-space optics for optical interconnects ...", SPIE Proc. 5556-02 (Inv. Pap.), Denver (CO), 2004

implementation: refractive optics (1)

example:
array imaging

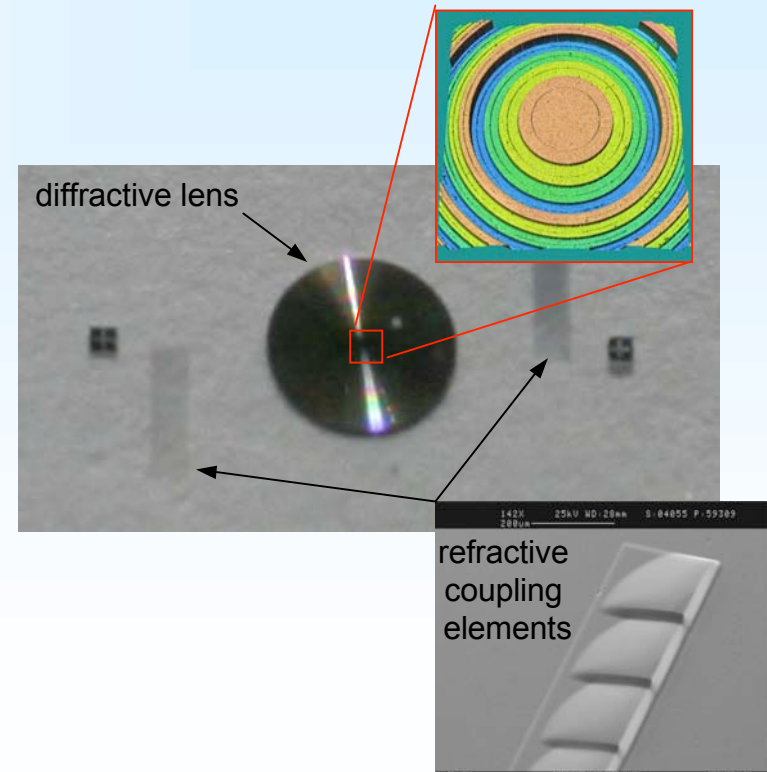


fabrication:

- HEBS mask
- gray-scale lithography (master)
- replication

characteristics:

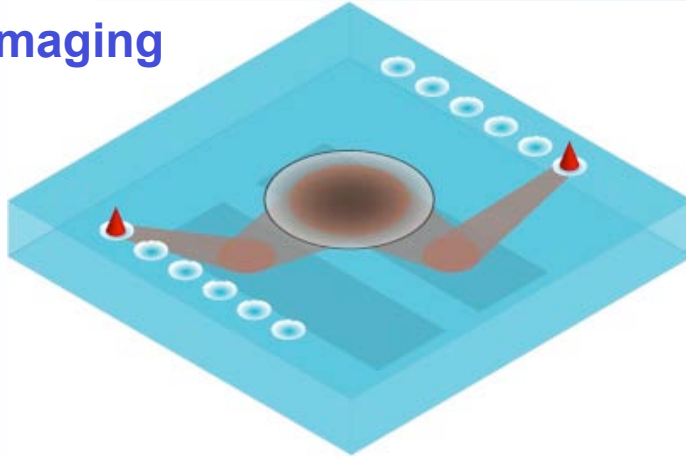
- $\eta_{\text{theor.}} = -2.1 \text{ dB}$
- $\eta_{\text{exp.}} \approx -4.4 \text{ dB}$
- crosstalk suppression: $> 38 \text{ dB}$
- single-mode operation



in cooperation with: IAP/FSU Jena and IOF/FhG Jena (2004/2005)

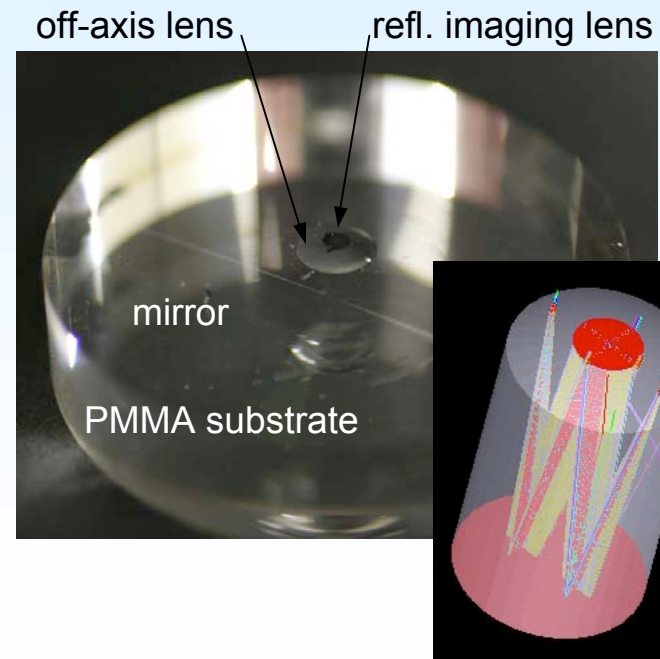
implementation: refractive optics (2)

example:
array imaging



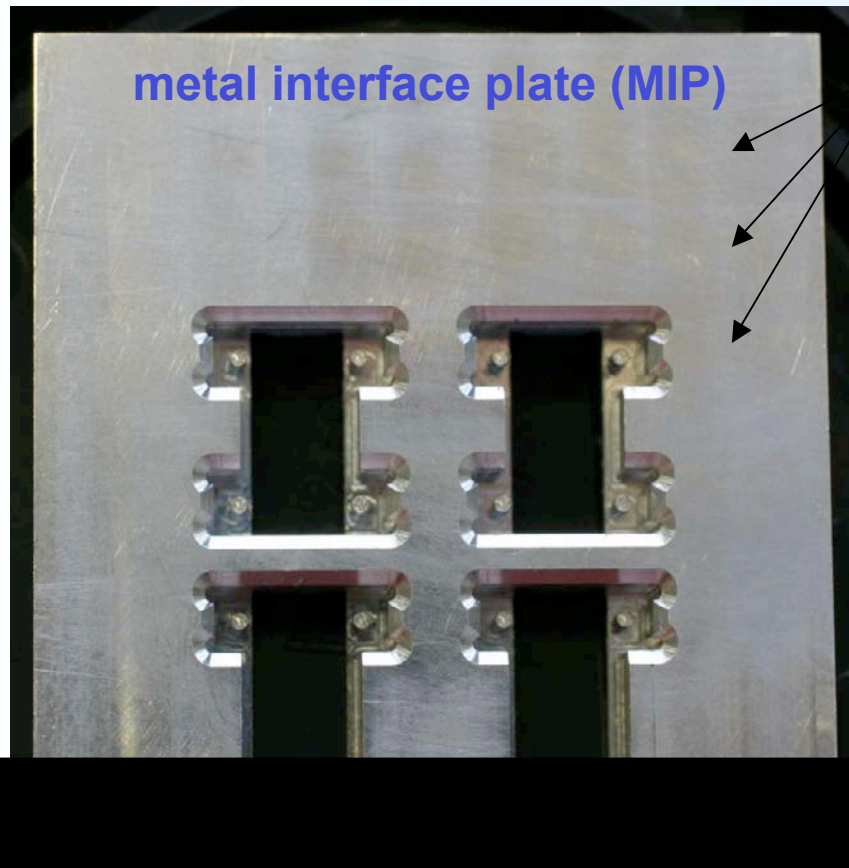
fabrication: - diamond turning
- PMMA substrate

characteristics: $\eta_{\text{theor.}} = -3.4 \text{ dB}$
 $\eta_{\text{exp.}} \approx \text{n.a.}$
crosstalk
suppression: n.a.



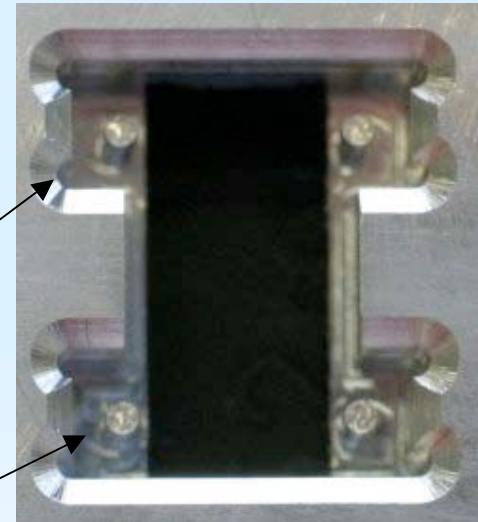
in cooperation with: IEO/NCTU, Taiwan (2005)

MT-interconnection



MT-sockets

MT-pins



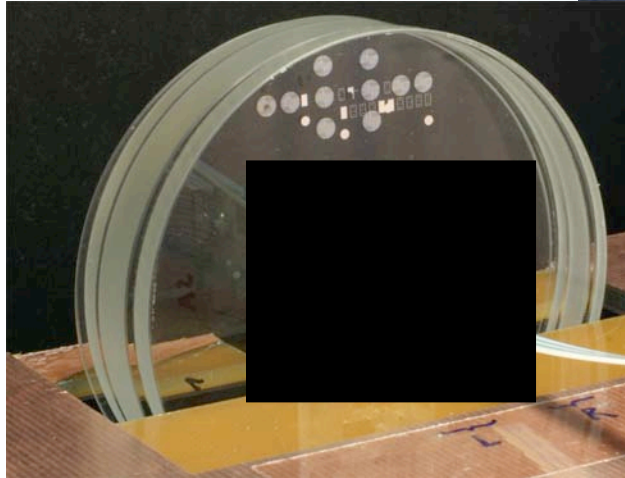
MT-connector



PCB-alignment

PIFSO-PCB interface

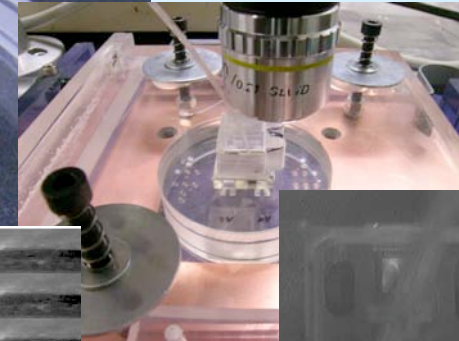
PIFSO module with assembled receptacles



assembly of PIFSO and PCB

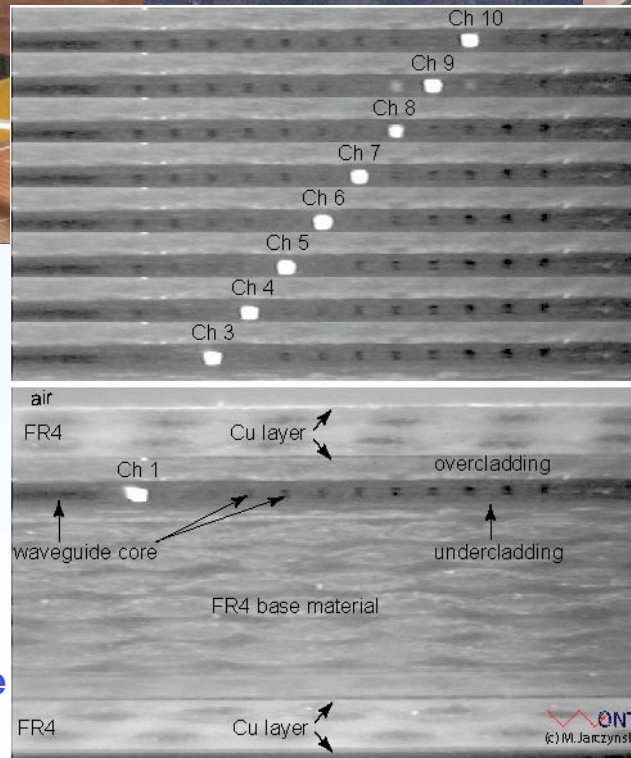


assembly setup



active alignment and assembly of PIFSO and receptacles

active channels of optical PCB after relay via MT-fibre bundle and PIFSO module



$\eta_{exp.}$ up to -6.5 dB
 crosstalk suppression:
 > 29.7 dB

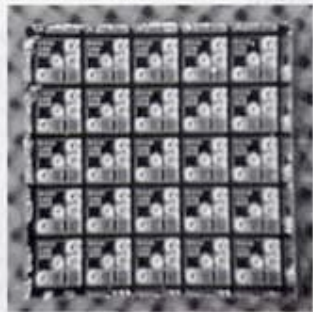
in cooperation with C-LAB, Siemens (2005)

laser sources - high density arrays

Photonik 5, 2003

VCSEL auf Glassubstrat

054 Die oberflächenemittierenden GaAs-Laserdioden der Baureihe Transsub-VCSEL (vertical cavity surface emitting laser)

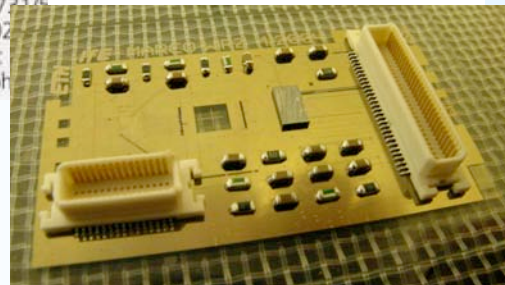


wurden für Emission bei 850 nm und 3,125 Gbps entwickelt. Als Substrat können 100 bis 300 µm dicke Wafer aus Glas an-

stelle von GaAs eingesetzt werden. Die P- und N-Kontakte (s. Bild, 5 x 5 VCSEL Array „von hinten“) sind wie bei einem SMD-Bauelement (surface mounted device) zugänglich, auch schon für den kostengünstigen Funktionstest im Wafer-Stadium. Das transparente Substrat schützt die Emitter-Oberseite und macht den VCSEL robust, auch z.B. für Anwendungen im Fahrzeugbau. Die Glasoberfläche oder Verbin-

rungsmittel rührt werden können.
ULM Photonik
Tel. 07231/5
Fax -02
eMail:
ulm-ph

opto-electronic multichip module



in cooperation with ETHZ and HWU, 2005

- integrated VCSEL-arrays on glass-substrates
- typical pitch 250 µm
- pitch of 50 µm and below are possible [1]
- typical SM power 1.5 mW [1]
- SM power ~ 5 mW achieved
- wavelength range 700 -1000 nm [2] and 1300-2050 nm [3]

[1] M. Grabherr, R. Jäger, R. King, B. Schneider, D. Wiedenmann, “Fabricating VCSELs in a high tech start-up”, SPIE-4942, 2002

[2] M. Grabherr, D. Wiedenmann, R. Jäger, R. King, “... tuneable single-mode VCSELs... 750 to 1000 nm range”, SPIE-5737, 2005

[3] www.semiconductorcompound.net, “Vertilasreleases32mW VCSEL arrays”

Important issues in real-world applications

- **insertion loss**
 - ! efficiency of optical elements
 - ! reflectivity of mirror coatings
- **tolerance**
 - ! optical
 - ! mechanical
 - ! thermal
- **competitiveness on the market**
 - ! cheap fabrication (replication technology)
- **compatibility within complex systems**
 - ! PIFSO - VCSEL/PD coupling
 - fiber/waveguide coupling
- **reliable systems**
 - ! packaging

summary

- **competences:**
 - micro-optical system integration
 - optical design
 - packaging for interconnects (PIFSO-to chip, -to-fibre, -to-PCB)
- **technical choices**
 - operational wavelength: 850 nm - 1500 nm
 - favored: VCSEL-arrays (singlemode)
 - transmission medium: typically quartz glass, but other possible
- **environmental issues**
 - good reliability of PIFS0
 - stable integration platform
- **figures of merit**
 - optical connectivity 1000 to 10000 mm⁻²
 - opto-electronic connectivity ~ 1000 mm⁻²
 - on-hand powerbudget for each optical stage ~ 20 dB